IN THE CLAIMS

Please amend the claims as follows:

- 1 (Currently Amended). A microphotonic device comprising:
- a deformable membrane structure that can experience strain using a plurality of
- 3 thin-film actuators that is directly formed on said deformable membrane, said strain is
- 4 continuous in the strain direction, said deformable membrane provides mechanical
- 5 support for said microphotonic device while providing high dielectric contrast with
- 6 relative to air underneath said deformable membrane; and
- a waveguide element formed on said deformable membrane structure so that
- 8 when said deformable membrane structure is strained, said waveguide element is tuned to
- 9 a selective amount.
- 2 (Previously Presented). The microphotonic device of claim 1, wherein said deformable
- 2 membrane structure comprises a sub-micron SiO₂ layer.
- 1 3 (Original). The microphotonic device of claim 1, wherein said waveguide element
- 2 comprises a microring resonator.
- 4 (Original). The microphotonic device of claim 1, wherein said waveguide element
- 2 comprises a microracetrack resonator.
- 5 (Original). The microphotonic device of claim 1, wherein said waveguide element
- 2 comprises a 1-dimensional photonic crystal.
- 6 (Original). The microphotonic device of claim 1, wherein said waveguide element
- 2 comprises a 2-dimensional photonic crystal.

- 7 (Original). The microphotonic device of claim 5, wherein said 1-dimensional photonic
- 2 crystal comprises holes.
- 8 (Original). The microphotonic device of claim 7, wherein said selective amount
- 2 comprises approximately 1%.
- 9 (Original). The microphotonic device of claim 3, wherein said selective amount
- 2 comprises 0.2%.
- 1 10 (Previously Presented). The microphotonic device of claim 1 further comprising at
- 2 least one piezoelectric actuator that is coupled to said deformable membrane so as to
- 3 produce said strain.
- 1 11 (Currently Amended). A method of forming a microphotonic device comprising:
- forming a deformable membrane structure that can experience strain using a
- 3 plurality of thin-film actuators that is directly formed on said deformable membrane, said
- 4 strain is continuous in the strain direction, said deformable membrane provides
- 5 mechanical support for said microphotonic device while providing high dielectric
- 6 contrast with relative to air underneath said deformable membrane; and
- forming a waveguide element on said deformable membrane structure so that
- 8 when said deformable membrane structure is strained said waveguide element is tuned to
- 9 a selective amount.
- 1 12 (Previously Presented). The method of claim 11, wherein said deformable membrane
- 2 structure comprises a sub-micron SiO₂ layer.

- 1 13 (Original). The method of claim 11, wherein said waveguide element comprises a
- 2 microring resonator.
- 1 14 (Original). The method of claim 11, wherein said waveguide element comprises a
- 2 microracetrack resonator.
- 1 15 (Original). The method of claim 11, wherein said waveguide element comprises a 1-
- 2 dimensional photonic crystal.
- 1 16 (Original). The method of claim 11, wherein said waveguide element comprises a 2-
- 2 dimensional photonic crystal.
- 1 17 (Original). The method of claim 15, wherein said 1-dimensional photonic crystal
- 2 comprises holes.
- 1 18 (Original). The method of claim 17, wherein said selective amount comprises
- 2 approximately 1%.
- 1 19 (Original). The method of claim 13, wherein said selective amount comprises 0.2%.
- 20 (Previously Presented). The method of claim 11 further comprising providing at least
- 2 one piezoelectric actuator that is coupled to said deformable membrane so as to produce
- 3 said strain.